Electrical transport properties in single-walled carbon nanotubes networks

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The electrical transport properties in single-walled carbon nanotube (SWCNT) networks have attracted much attention since the last two decades, because of both their promising applications ^[1] and their intriguing physical properties ^[2]. In this work, we study the temperature (*T*) and the magnetic-field (*B*) dependences of electrical transport properties in single-walled carbon nanotube (SWCNT) networks.

SWCNTs were grown by no-flow alcohol catalytic chemical vapor deposition ^[3] and dispersed in dimethylformamide. They had a bundle diameter $\mathbf{\sigma}$ about 15 nm, as characterized by scanning electron microscopy. They were printed on SiO₂ substrates by an ink-jet method ^[4] and palladium electrodes were subsequently patterned on the devices using a metallic mask and electron beam physical vapor deposition. The two-terminal transport measurements were carried out at T = 0.5 - 295 K using a variable-temperature cryogenic system and a dilution refrigerator.

First, we carefully checked the current-voltage (I-V) characteristics. The measured I-V curves are linear at temperatures down to T = 0.5 K, establishing the ohmic behaviors of both the samples and the electrical contacts. Figure 1 shows the temperature dependence of the resistance (*R*) estimated from the I-V curves: the natural logarithm $\ln(R)$ exhibits a linear relationship with $T^{1/3}$, demonstrating that a 2D Mott variable-range hopping transport ^[5] is dominant in the SWCNT networks throughout the whole measurement temperature range.

Next, we measured the magnetoresistance R(B) at different T. The obtained R(B) curves are plotted in Figure 2. At T = 4.3 and 5 K, R(B) shows a minimum at about 2.5 - 3 T. We found that this minimum drastically moved down towards the low *B*-fields to approximately 0.5 T at T = 1 and 1.6 K. This can be interpreted as the suppression of the quantum-interference effects in the variable-range hopping regime of disordered systems at low $T^{[6]}$.

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Figures

Fig. 1. Linear relationship between $\ln(R)$ and $T^{1/3}$ observed in SWCNT networks and indicating a 2D Mott variable-range hopping transport mechanism.



Fig. 2. Magnetoresistance R(B) in single-walled carbon nanotube network samples as a function of the magnetic field B: $\ln[R(B)/R(0)]$ is plotted *versus B* at various temperatures.

